Crystal structures and Hirshfeld surface analyses of bis(4,5-dihydrofuran-2-yl)dimethylsilane and (4,5-dihydrofuran-2-yl)(methyl)diphenylsilane

Annika Schmidt, Anna Krupp, Eva Rebecca Barth and Carsten Strohmann*

Technische Universität Dortmund, Fakultät für Chemie und chemische Biologie, Anorganische Chemie, Otto-Hahn-Strasse 6, 44227 Dortmund, Germany. *Correspondence e-mail: carsten.strohmann@tu-dortmund.de

The title compounds, $C_{10}H_{16}O_2Si$ (1) and $C_{17}H_{18}OSi$ (2), are classified as dihydrofurylsilanes, which show great potential as building blocks for various functionalized silanes. They both crystallize in the space group $P\overline{1}$ in the triclinic crystal system. Analyses of the Hirshfeld surfaces show packing-determining interactions for both compounds, resulting in a polymeric chain along the [011] for silane 1 and a layered-interconnected structure along the b-axis direction for silane 2.

1. Chemical context

Dihydrofurylsilanes are interesting starting materials for tailor-made silicon compounds. First presented in the 1980s by Lukevics (Lukevics et al., 1985), they turned out to be versatile building blocks for multiple silicon compound classes. Tetrasubstituted silicon compounds are obtainable as a result of the excellent nature of the dihydrofuryl (DHF) substituent as a leaving group in various nucleophilic substitutions at the silicon atom. Si-C(DHF) bond cleavages under substitution of the dihydrofuryl group was observed for the reactions with C-nucleophiles (e.g. organolithium compounds) (Gevorgyan et al., 1992), H-nucleophiles (e.g. LiAlH₄, NaH, NaBH₄) (Gevorgyan et al., 1989, 1990), O-nucleophiles (e.g. t-butanol) and N-nucleophiles [e.g. LiN(Et)₂] (Lukevics et al., 1997). By means of this efficient pathway, a noteworthy approach to pentacoordinated organyl silatranes has been made (Gevorgyan et al., 1997), as well as for (α -aminomethyl)silanes (Labrecque et al., 1994). Along with their easy preparation and hydrolytical and chromatographical stability (Gevorgyan et al., 1997), dihydrofurylsilanes offer the potential to be useful reagents as protecting groups for the synthesis of aminomethylsilazanes (Colquhoun et al., 2011; Colquhoun & Strohmann, 2012).



Herein, we report the structures of two further dihydrofurylsilanes, bis(4,5-dihydrofuran-2-yl)dimethylsilane (1) and



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Table 1

Selected geometric parameters for compound $1 (A, \circ)$.					
Si1-C1	1.8742 (3)	C1-Si1-C5	108.189 (12)		
Si1-C5	1.8693 (3)	C1-Si1-C9	106.801 (14)		
Si1-C9	1.8631 (3)	C1-Si1-C10	109.191 (13)		
Si1-C10	1.8579 (3)	C5-Si1-C9	110.770 (15)		
		C5-Si1-C10	108.128 (13)		
C1-C2	1.3370 (4)	C9-Si1-C10	113.628 (16)		
C3-C4	1.5331 (5)				
C5-C6	1.3409 (4)				
C7-C8	1.5298 (5)				

(4,5-dihydrofuran-2-yl)(methyl)diphenylsilane (2) and their structural analysis, supplemented by a Hirshfeld surface analysis.

2. Structural commentary

The molecular structure of 1 is given in Fig. 1 and selected bond lengths and angles are given in Table 1. Compound 1 shows C_2 molecular symmetry. The lengths of the Si-C(DHF) bonds are similar but slightly longer than the lengths of the Si-C(Me) bonds. However, all bonds have characteristic dimensions (Allen et al., 1987). Furthermore, the length of the C=C double bond corresponds well with literature values (Allen et al., 1987) and is clearly shortened in comparison to the C-C single bonds in the dihydrofuranyl substituent. The silicon atom is tetrahedrally surrounded by its substituents, however slightly distorted as evident from the slight deviations from the ideal angle of 109.47°. These deviations are congruent with a former publication on dihydrofurylsilanes (Krupp et al., 2020). Both DHF planes display planarity while the C1–C4/O1 ring has an r.m.s. deviation of 0.0197 Å from an ideal least-squares plane with atom C4 showing the largest deviation of -0.0269 (2) Å. The C5–C8/O2 ring deviates more strongly from an ideal least-square plane with an r.m.s.



Figure 1

The molecular structure of compound 1 with displacement ellipsoids drawn at the 50% probability level.

Table 2			
Selected geometric parameters for compound	2 (Å.	°).

6		• • • •	
Si1-C1	1.8742 (10)	C1-Si1-C5	108.44 (4)
Si1-C5	1.8721 (9)	C1-Si1-C11	105.51 (4)
Si1-C11	1.8713 (10)	C1-Si1-C17	109.26 (5)
Si1-C17	1.8591 (11)	C5-Si1-C11	113.08 (4)
		C5-Si1-C17	110.49 (5)
C1-C2	1.3356 (14)	C11-Si1-C17	109.88 (59
C3-C4	1.5416 (17)		

deviation of 0.0608 Å, with the C8 atom deviating the most by 0.0838 (2) Å. The angle between the normals of the least-squares planes through the DHF rings is 78.943 (15)°.

The molecular structure of **2** is given in Fig. 2 and selected bond lengths and angles are given in Table 2. The length of the Si-C(DHF) bond is in the range of the lengths of the Si-C(Ph) bonds, which are again slightly longer than the Si-C(Me) bond. The bond lengths of the dihydrofuran ring are consistent with those of structure **1**. Again, a slightly distorted tetrahedral environment at the silicon atom is observed. The DHF ring is less planar than the phenyl rings, with an r.m.s. deviation from the least-squares plane of 0.0426 Å with the C4 atom having the largest deviation of -0.0582 (7) Å. The phenyl rings show r.m.s. deviations of 0.0066 and 0.0047 Å. The angle between the normals of the least-squares planes of the DHF ring and the C5–C10 phenyl ring is 87.68 (4)° and the angle between the normals of the least-squares planes of the phenyl rings is 60.03 (4)°.

3. Supramolecular features

The crystal packing of compound **1** is defined by C10– H10 $A \cdot \cdot \cdot C2^{i}$ van der Waals interactions as can be seen in Fig. 3. The interactions show relatively large distances [C10 $\cdot \cdot \cdot C2^{i}$ = 3.6208 (5) Å, H10 $A \cdot \cdot \cdot C2^{i}$ = 2.752 (10) Å and C10–



Figure 2

The molecular structure of compound 2 with displacement ellipsoids drawn at the 50% probability level.

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Figure 3

The crystal packing of compound **1**. $C-H \cdots C$ van der Waals interactions are shown as dashed lines.



Figure 4

The crystal packing of compound **1** with the (011) plane shaded in blue. $C-H\cdots C$ van der Waals interactions are shown as dashed lines.

H10 $A \cdots C2^i = 148.4$ (8)°; symmetry code: (i) -x + 1, -y + 2, -z]. As a result of the interactions between carbon atom C2 and hydrogen atom H10A, a polymeric chain structure along the [011] direction is formed (Fig. 4). The interactions can be displayed by a Hirshfeld surface analysis (Spackman & Jaya-tilaka, 2009) generated by *CrystalExplorer21* (Spackman *et al.*, 2021), here indicated by the red spots (Fig. 5). The Hirshfeld surface mapped over d_{norm} is in the range from -0.0783 to 1.0981 a.u. The contributions of the different types of intermolecular interactions for **1** are shown in the two-dimensional



Two-dimensional fingerprint plots for compound 1, showing (a) all contributions, and (b)-(d) delineated showing the contributions of atoms within specific interacting pairs (blue areas).

fingerprint plots (McKinnon *et al.*, 2007) in Fig. 6. The contribution of the $H \cdots H$ interactions, with a value of 76.4%, has the largest share of the crystal packing of **1**. The $O \cdots H/H \cdots O$ interactions have a smaller share with a 15% contribution and the $C \cdots H/H \cdots C$ interactions with a 8.6% contribution. Both heteronuclear interactions appear as spikes.

The structure of compound **2** is more strongly defined by $C-H\cdots O$ hydrogen bonds (Fig. 7, Table 3). Two different layers are formed along the *b*-axis direction and interconnected by hydrogen bonds between the O1 atom and the H17*C* atom. An additional interaction in each of the layers is observed by $C-H\cdots O$ hydrogen bonds between the O1 atom



Figure 5

Hirshfeld surface analysis of **1** showing close contacts in the crystal. The van der Waals interaction between carbon atom C2 and the H10A hydrogen atom is labeled. [Symmetry code: (i) -x + 1, -y + 2, -z].



Figure 7 The crystal packing of compound 2. $C-H\cdots O$ hydrogen bonds are shown as dashed lines.

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Table 3	
Hydrogen-bond geometry (Å, $^{\circ}$) for 2 .	

$D - H \cdot \cdot \cdot A$	D-H	$H \cdot \cdot \cdot A$	$D \cdot \cdot \cdot A$	$D - H \cdots $
$\begin{array}{c} C15-H15\cdots O1^{i}\\ C17-H17C\cdots O1^{ii} \end{array}$	0.969 (16)	2.640 (16)	3.3422 (13)	129.6 (12)
	0.992 (19)	2.584 (19)	3.5168 (14)	156.5 (15)

Symmetry codes: (i) x, y + 1, z; (ii) -x + 2, -y + 1, -z + 1.

and the H15 atom. The C17—H17C···O1ⁱⁱ hydrogen bond can be described by the $R_2^2(10)$ graph-set motif and the C15— H15···O1ⁱ hydrogen bond by the $C_1^1(7)$ graph-set motif (Etter *et al.*, 1990). Both C—H···O hydrogen bonds can be identified as weak interactions according to Desiraju & Steiner (2001). A Hirshfeld analysis, carried out analogously as for structure **1**, was used to further study the crystal packing. In Fig. 8, the nearest contacts are shown in red. The Hirshfeld surface mapped over d_{norm} is in the range from -0.0717 to 1.0768 a.u. By analysis of the two-dimensional fingerprint plots (Fig. 9), again, the biggest contribution to the crystal packing can be assigned to H···H interactions (66%). Although the closest contacts were identified as C—H···O hydrogen bonds, O···H/ H···O interactions contribute only 6.4% to the crystal



Figure 8

Hirshfeld surface analysis of **2** showing close contacts in the crystal. The weak hydrogen bond between oxygen atom O1 and the H15 hydrogen atom, as well as the weak hydrogen bonds between the oxygen atom O1 and the H17*C* hydrogen atom are labeled. [Symmetry codes: (i) x, y + 1, z; (ii) -x + 2, -y + 1, -z + 1].



Figure 9

Two-dimensional fingerprint plots for compound **2**, showing (*a*) all contributions, and (b)-(d) delineated showing the contributions of atoms within specific interacting pairs (blue areas).

packing, while $C \cdots H/H \cdots C$ interactions have a larger share of 27%.

4. Database survey

A search of the Cambridge Crystallographic Database (WebCSD, November 2021; Groom et al., 2016) for 2-(4,5dihydrofuryl)silanes revealed solely the structures of tris(4,5dihydrofuran-2-yl)methylsilane and tris(4,5-dihydrofuran-2yl)phenylsilane published by our group previously (Krupp et al., 2020). A more extended search for 3-(4,5-dihydrofuryl)silane gave some structures with substituted dihydrofuran rings, such as [4-(4-fluorophenyl)-5-(4-nitrophenyl)-4,5-dihydrofuran-3-yl](trimethyl)silane (JIVLIM; Li & Zhang, 2018), rac-5-phenyl-4-(t-butyldiphenylsilyl)-2,3-dihydrofuran-2-carboxylic acid ethyl ester (PUXCAM; Evans et al., 2001) (1'S,2R)-5-methyl-4-(t-butyldiphenylsilyl)-2,3-dihydroand furan-2-carboxylic acid (1'-phenylethyl)amide (PUXCEQ; Evans et al., 2001). Contrary to the here and previously presented 2-(4,5-dihydrofuryl)silanes (Krupp et al., 2020), the published 3-(4,5-dihydrofuryl)silanes do not show an elongated Si-C(DHF) bond in comparison to the other substituents at the silicon atom. This can be attributed to the changed connection on the DHF ring. The slightly distorted tetrahedral silicon atom can be observed in all structures as well as the shortened C=C double bond in the DHF ring.

5. Synthesis and crystallization

Bis(4,5-dihydrofuran-2-yl)dimethylsilane (1) as already described by Lukevics and co-workers (Lukevics *et al.*, 1985)

Table 4Experimental details.

	1	2
Crystal data		
Chemical formula	$C_{10}H_{16}O_2Si$	C ₁₇ H ₁₈ OSi
М.	196.32	266.40
Crystal system, space group	Triclinic, $P\overline{1}$	Triclinic, $P\overline{1}$
Temperature (K)	100	100
<i>a</i> , <i>b</i> , <i>c</i> (Å)	8.2422 (3), 8.3075 (4), 8.2940 (4)	8.7737 (4), 9.1715 (4), 9.8130 (4)
α, β, γ (°)	94.149 (2), 103.012 (1), 104.909 (1)	102.219 (2), 90.613 (2), 110.280 (2)
$V(\dot{A}^3)$	529.55 (4)	720.85 (6)
Z	2	2
Radiation type	Μο Κα	Μο Κα
$\mu (\text{mm}^{-1})$	0.19	0.15
Crystal size (mm)	$0.72 \times 0.66 \times 0.59$	$0.51\times0.19\times0.07$
Data collection		
Diffractometer	Bruker D8 Venture	Bruker D8 Venture
Absorption correction	Multi-scan (SADABS; Krause et al., 2015)	Multi-scan (SADABS; Krause et al., 2015)
T_{\min}, T_{\max}	0.519, 0.576	0.713, 0.747
No. of measured, independent and observed $[I > 2\sigma(I)]$ reflections	256332, 11412, 10306	20409, 5826, 4937
R _{int}	0.032	0.030
$(\sin \theta / \lambda)_{\rm max} ({\rm \AA}^{-1})$	1.089	0.787
Refinement		
$R[F^2 > 2\sigma(F^2)], wR(F^2), S$	0.026, 0.089, 1.06	0.040, 0.105, 1.06
No. of reflections	11412	5826
No. of parameters	182	244
H-atom treatment	H atoms treated by a mixture of independent and constrained refinement	H atoms treated by a mixture of independent and constrained refinement
$\Delta \rho_{\rm max}, \Delta \rho_{\rm min} \ ({\rm e} \ {\rm \AA}^{-3})$	0.68, -0.32	0.48, -0.27

Computer programs: APEX2 (Bruker, 2018), SAINT (Bruker, 2016), SHELXS (Sheldrick, 2008), SHELXL2014/7 (Sheldrick, 2015), OLEX2 (Dolomanov et al., 2009), publCIF (Westrip, 2010) and Mercury (Macrae et al., 2020).

was synthesized by adding ¹BuLi (1.9 *M* in pentane, 8.16 mL, 15.5 mmol, 2.0 eq.) to a solution of 2,3-dihydrofuran (1.09 g, 15.5 mmol, 2.0 eq.) in diethyl ether at 243 K and subsequent stirring for an hour. Dichlorodimethylsilane (1.00 g, 7.75 mmol, 1.0 eq.) was added at 243 K and warmed to room temperature under stirring for 2 h. All solids were filtered off inertly and all volatile components were removed *in vacuo*. After cleaning by Kugelrohr distillation (temperature: 373 K, pressure: 2.1×10^{-1} mbar), bis(4,5-dihydrofuran-2-yl)dimethylsilane (1) (1.50 g, 7.65 mmol, 99%) was obtained as a colorless oil. By crystallization from diethyl ether at 193 K, colorless blocks were obtained.

¹H NMR (400.25 MHz, C₆D₆): $\delta = 0.39$ [*s*, 6H; Si(CH₃)₂], 2.27 [*dt*, ³*J*_{HH} = 2.57 Hz, ³*J*_{HH} = 9.78 Hz, 4H; Si(CCHCH₂)₂], 4.07 [*t*, ³*J*_{HH} = 9.78 Hz, 4H; Si(COCH₂)₂], 5.31 [*t*, ³*J*_{HH} = 2.57 Hz, 2H; Si(CCH)₂] ppm.

{¹H}¹³C NMR (100.6 MHz, C₆D₆): $\delta = -3.8$ [2C; (SiCH₃)₂], 31.6 [2C; Si(CCHCH₂)₂)], 71.8 [2C; Si(COCH₂)₂], 113.4 [2C; Si(COCH₂)₂], 160.0 [2C; Si(CO)₂] ppm.

 ${^{1}H}^{29}Si$ NMR (79.52 MHz, C₆D₆): $\delta = -22.29$ [1Si; *Si*(DHF)₂] ppm.

GC/EI–MS: $t_{\rm R} = 3.94$ min [353 K (1 min) – 40 K min⁻¹ – 543 K (5.5 min)]; m/z (%): 196 (94) [M^+], 181 (2) [$(M - {\rm Me})^+$], 167 (14) [$(M - {\rm CHO})^+$], 153 (40) [$(M - {\rm C}_2{\rm H}_3{\rm O})^+$], 97 (100) [(SiDHF)⁺].

(4,5-Dihydrofuran-2-yl)(methyl)diphenylsilane (**2**), already described by Tsai and co-workers (Tsai *et al.*, 1992) by

cyclization of a haloacylsilane, was synthesized analogously to **1**. 'BuLi (1.90 *M* in pentane, 21.5 mmol, 11.3 mL, 1.00 eq.) was slowly added dropwise to a solution of 2,3-dihydrofuran (1.51 g, 21.5 mmol, 1.00 eq.) in diethyl ether (80 mL) at 243 K and the reaction solution was stirred for 1h at this temperature. Methyldiphenylchlorosilane (5.00 g, 21.5 mmol, 1.00 eq.) was then added at 243 K and the reaction solution was stirred at room temperature overnight. All solids were separated by inert filtration and the solvent was removed *in vacuo*. The residue was purified by Kugelrohr distillation (temperature: 453 K, pressure: 2.0×10^{-1} mbar) and the product **2** (5.11 g, 19.2 mmol, 89%) was obtained as a colorless liquid. By crystallization from pentane at 193 K, colorless platelets were obtained.

¹H NMR (400.25 MHz, C_6D_6): $\delta = 0.69$ (*s*, 3H; SiCH₃), 2.24 (*dt*, ³*J*_{HH} = 2.57Hz, ³*J*_{HH} = 9.66 Hz, 2H; SiCCHCH₂), 4.07 (*t*, ³*J*_{HH} = 9.66 Hz, 2H; SiCOCH₂), 5.20 (*t*, ³*J*_{HH} = 2.57 Hz, 1H; SiCCH), 7.18–7.21 (*m*, 6H; CH_{ortho,para}), 7.71–7.73 (*m*, 4H; CH_{meta}) ppm.

{¹H}¹³C NMR (100.65 MHz, C₆D₆): $\delta = -3.9$ (1C; SiCH₃), 31.3 (1C; SiCCHCH₂), 71.1 (1C; SiCOCH₂), 115.5 (1C; SiCCH), 128.5 (2C, C_{ortho}), 130.2 (1C, C_{para}), 135.8 (2C, C_{meta}), 135.8 (1C, C_{ipso}), 160.2 (1C, SiCO) ppm.

 ${^{1}H}^{29}Si$ NMR (79.52 MHz, C₆D₆): $\delta = -19.51$ (s, 1Si; SiDHF) ppm.

GC/EI–MS: $t_{\rm R} = 5.97 \text{ min} [353 \text{ K} (1 \text{ min}) - 40 \text{ K} \text{ min}^{-1} - 543 \text{ K} (5.5 \text{ min})]; m/z (\%): 266 (100) [M⁺], 251 (33)$

 $[(M - Me)^+], 238 (27) [(M - C_2H_4)^+], 222 (20)$ $[(M - C_2H_4O)^+], 197 (75) [(M - DHF)^+], 105 (52) [(SiPh)^+], 77 (6) [(Ph)^+].$

6. Refinement

Crystal data, data collection and structure refinement details are summarized in Table 4. H atoms were positioned geometrically (C-H = 0.95–1.00 Å) and were refined using a riding model, with $U_{iso}(H) = 1.2U_{eq}(C)$ for CH₂ and CH hydrogen atoms and $U_{iso}(H) = 1.5U_{eq}(C)$ for CH₃ hydrogen atoms. Hydrogen atoms H2 and H6 for compound **1** and H2, H15 and H17*C* for compound **2** were refined independently.

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Annika Schmidt, Anna Krupp, Eva Rebecca Barth and Carsten Strohmann

Computing details

For both structures, data collection: *APEX2* (Bruker, 2018); cell refinement: *SAINT* (Bruker, 2016); data reduction: *SAINT* (Bruker, 2016); program(s) used to solve structure: *SHELXS* (Sheldrick, 2008); program(s) used to refine structure: *SHELXL2014*/7 (Sheldrick, 2015); molecular graphics: *OLEX2* (Dolomanov *et al.*, 2009); software used to prepare material for publication: *OLEX2* (Dolomanov *et al.*, 2009), CrystalExplorer21 (Spackman *et al.*, 2021), *publCIF* (Westrip, 2010), *Mercury* (Macrae *et al.*, 2020).

Bis(4,5-dihydrofuran-2-yl)dimethylsilane (1)

Crystal data

C₁₀H₁₆O₂Si $M_r = 196.32$ Triclinic, $P\overline{1}$ a = 8.2422 (3) Å b = 8.3075 (4) Å c = 8.2940 (4) Å $\alpha = 94.149$ (2)° $\beta = 103.012$ (1)° $\gamma = 104.909$ (1)° V = 529.55 (4) Å³

Data collection

Bruker D8 Venture diffractometer Radiation source: microfocus sealed X-ray tube, Incoatec I μ s Mirror optics monochromator Detector resolution: 7.9 pixels mm⁻¹ ω and φ scans Absorption correction: multi-scan (SADABS; Krause et al., 2015)

Refinement

Refinement on F^2 Least-squares matrix: full $R[F^2 > 2\sigma(F^2)] =$ 0.026 $wR(F^2) = 0.089$ S = 1.06 Z = 2 F(000) = 212 $D_x = 1.231 \text{ Mg m}^{-3}$ Mo K α radiation, $\lambda = 0.71073 \text{ Å}$ Cell parameters from 8689 reflections $\theta = 2.5-20.9^{\circ}$ $\mu = 0.19 \text{ mm}^{-1}$ T = 100 KBlock, colourless $0.72 \times 0.66 \times 0.59 \text{ mm}$

 $T_{\min} = 0.519, T_{\max} = 0.576$ 256332 measured reflections
11412 independent reflections
10306 reflections with $I > 2\sigma(I)$ $R_{\text{int}} = 0.032$ $\theta_{\text{max}} = 50.7^{\circ}, \theta_{\text{min}} = 2.6^{\circ}$ $h = -16 \rightarrow 17$ $k = -18 \rightarrow 18$ $l = -18 \rightarrow 18$

11412 reflections
182 parameters
0 restraints
Primary atom site location: iterative
Hydrogen site location: difference Fourier map
H atoms treated by a mixture of independent and constrained refinem

 $w = 1/[\sigma^2(F_o^2) + (0.0535P)^2 + 0.0207P]$ where $P = (F_o^2 + 2F_c^2)/3$ $(\Delta/\sigma)_{\text{max}} = 0.002$ $\Delta \rho_{\rm max} = 0.68 \text{ e } \text{\AA}^{-3}$ $\Delta \rho_{\rm min} = -0.32 \text{ e } \text{\AA}^{-3}$

Special details

Geometry. All esds (except the esd in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell esds are taken into account individually in the estimation of esds in distances, angles and torsion angles; correlations between esds in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell esds is used for estimating esds involving l.s. planes.

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters (A^2)

	x	у	Ζ	$U_{\rm iso}$ */ $U_{\rm eq}$
Si1	0.64185 (2)	0.82439 (2)	0.20897 (2)	0.01354 (2)
01	0.28272 (3)	0.68623 (3)	0.09023 (4)	0.02227 (4)
O2	0.70145 (4)	0.71875 (3)	0.52219 (3)	0.02213 (4)
C1	0.41042 (3)	0.81964 (3)	0.19462 (3)	0.01504 (3)
C2	0.34535 (4)	0.92843 (4)	0.26763 (4)	0.01740 (4)
C3	0.14995 (4)	0.87390 (4)	0.21112 (4)	0.02057 (4)
H3A	0.0906 (12)	0.8525 (12)	0.3024 (12)	0.033 (2)*
H3B	0.1063 (12)	0.9549 (11)	0.1543 (11)	0.032 (2)*
C4	0.11591 (4)	0.70688 (5)	0.10008 (5)	0.02242 (5)
H4A	0.0538 (11)	0.6100 (11)	0.1453 (11)	0.032 (2)*
H4B	0.0486 (12)	0.6963 (12)	-0.0129 (12)	0.037 (2)*
C5	0.70144 (3)	0.67768 (3)	0.35736 (3)	0.01419 (3)
C6	0.73403 (4)	0.52967 (3)	0.32841 (3)	0.01609 (4)
C7	0.75301 (4)	0.44890 (4)	0.48628 (4)	0.01889 (4)
H7A	0.8533 (11)	0.4108 (11)	0.5151 (11)	0.0284 (18)*
H7B	0.6498 (10)	0.3515 (11)	0.4771 (10)	0.0251 (17)*
C8	0.75865 (6)	0.59310 (5)	0.61494 (4)	0.02397 (6)
H8A	0.6831 (12)	0.5602 (11)	0.6876 (12)	0.033 (2)*
H8B	0.8762 (14)	0.6488 (14)	0.6853 (14)	0.048 (3)*
C9	0.77560 (4)	1.04490 (4)	0.28985 (5)	0.02162 (5)
H9A	0.7566 (12)	1.0847 (12)	0.3964 (12)	0.037 (2)*
H9B	0.9008 (14)	1.0571 (13)	0.3185 (14)	0.048 (3)*
H9C	0.7555 (14)	1.1226 (14)	0.2124 (13)	0.047 (3)*
C10	0.66177 (4)	0.74698 (4)	0.00048 (4)	0.01893 (4)
H10A	0.6108 (13)	0.8064 (13)	-0.0859 (13)	0.040 (2)*
H10B	0.6006 (14)	0.6296 (14)	-0.0355 (13)	0.045 (3)*
H10C	0.7765 (13)	0.7669 (12)	-0.0041 (12)	0.036 (2)*
H6	0.7325 (10)	0.4798 (10)	0.2272 (10)	0.0225 (16)*
H2	0.4137 (12)	1.0273 (11)	0.3403 (11)	0.033 (2)*

Atomic displacement parameters $(Å^2)$

	U^{11}	U^{22}	U^{33}	U^{12}	U^{13}	U^{23}
Si1	0.01424 (3)	0.01281 (3)	0.01491 (3)	0.00527 (2)	0.00450 (2)	0.00244 (2)
01	0.01651 (7)	0.02070 (9)	0.02720 (10)	0.00574 (6)	0.00287 (7)	-0.00545 (7)
O2	0.03579 (12)	0.02135 (9)	0.01466 (7)	0.01572 (9)	0.00835 (7)	0.00268 (6)

C1	0.01497 (7)	0.01501 (7)	0.01637 (8)	0.00611 (6)	0.00417 (6)	0.00253 (6)
C2	0.01676 (8)	0.01709 (8)	0.01982 (9)	0.00723 (7)	0.00523 (7)	0.00100 (7)
C3	0.01692 (9)	0.02220 (11)	0.02551 (12)	0.00930 (8)	0.00669 (8)	0.00381 (9)
C4	0.01543 (9)	0.02642 (13)	0.02320 (11)	0.00544 (8)	0.00243 (8)	-0.00117 (9)
C5	0.01579 (7)	0.01407 (7)	0.01381 (7)	0.00590 (6)	0.00406 (6)	0.00171 (5)
C6	0.01916 (9)	0.01436 (8)	0.01617 (8)	0.00689 (6)	0.00502 (7)	0.00142 (6)
C7	0.02225 (10)	0.01595 (8)	0.02068 (10)	0.00752 (7)	0.00644 (8)	0.00561 (7)
C8	0.03680 (17)	0.02108 (11)	0.01494 (9)	0.01061 (11)	0.00498 (9)	0.00432 (8)
C9	0.02043 (10)	0.01447 (9)	0.02932 (13)	0.00399 (7)	0.00669 (9)	0.00107 (8)
C10	0.02063 (10)	0.02226 (10)	0.01611 (9)	0.00769 (8)	0.00686 (7)	0.00360 (7)

Geometric parameters (Å, °)

Sil—Cl	1.8742 (3)	C4—H4B	0.961 (10)
Si1—C5	1.8693 (3)	C5—C6	1.3409 (4)
Si1—C9	1.8631 (3)	C6—C7	1.5093 (4)
Si1—C10	1.8579 (3)	С6—Н6	0.904 (8)
O1—C1	1.3915 (4)	С7—Н7А	0.947 (9)
O1—C4	1.4479 (4)	С7—Н7В	0.996 (8)
O2—C5	1.3849 (3)	C7—C8	1.5298 (5)
O2—C8	1.4525 (4)	C8—H8A	0.965 (9)
C1—C2	1.3370 (4)	C8—H8B	0.984 (11)
C2—C3	1.5075 (4)	С9—Н9А	0.980 (10)
С2—Н2	0.945 (9)	С9—Н9В	0.982 (11)
С3—НЗА	0.992 (9)	С9—Н9С	0.961 (11)
С3—Н3В	0.948 (9)	C10—H10A	0.978 (10)
C3—C4	1.5331 (5)	C10—H10B	0.965 (11)
C4—H4A	0.984 (9)	C10—H10C	0.927 (10)
C5—Si1—C1	108.189 (12)	C6—C5—O2	113.03 (2)
C9—Si1—C1	106.801 (14)	C5—C6—C7	109.72 (2)
C9—Si1—C5	110.770 (15)	С5—С6—Н6	125.3 (5)
C10—Si1—C1	109.191 (13)	С7—С6—Н6	124.7 (5)
C10—Si1—C5	108.128 (13)	С6—С7—Н7А	114.8 (5)
C10—Si1—C9	113.628 (16)	С6—С7—Н7В	110.3 (5)
C1—O1—C4	107.60 (2)	C6—C7—C8	101.18 (2)
C5—O2—C8	107.15 (2)	H7A—C7—H7B	107.9 (7)
O1—C1—Si1	117.093 (19)	C8—C7—H7A	111.6 (5)
C2—C1—Si1	129.94 (2)	С8—С7—Н7В	110.9 (5)
C2—C1—O1	112.95 (2)	O2—C8—C7	106.95 (2)
C1—C2—C3	110.20 (3)	O2—C8—H8A	107.7 (6)
C1—C2—H2	124.1 (5)	O2—C8—H8B	106.9 (6)
С3—С2—Н2	125.7 (5)	С7—С8—Н8А	113.7 (6)
С2—С3—Н3А	114.7 (5)	С7—С8—Н8В	113.2 (6)
С2—С3—Н3В	111.8 (5)	H8A—C8—H8B	108.0 (8)
C2—C3—C4	101.57 (2)	Si1—C9—H9A	111.7 (5)
НЗА—СЗ—НЗВ	106.4 (7)	Si1—C9—H9B	113.1 (6)
С4—С3—Н3А	108.8 (5)	Si1—C9—H9C	113.1 (6)

C4—C3—H3B	113.8 (5)	Н9А—С9—Н9В	102.7 (8)
O1—C4—C3	107.47 (3)	Н9А—С9—Н9С	108.8 (8)
O1—C4—H4A	108.9 (5)	H9B—C9—H9C	106.8 (9)
O1—C4—H4B	106.6 (6)	Si1-C10-H10A	111.1 (6)
C3—C4—H4A	112.4 (5)	Si1-C10-H10B	112.9 (6)
C3—C4—H4B	116.7 (6)	Si1-C10-H10C	112.3 (6)
H4A—C4—H4B	104.5 (8)	H10A-C10-H10B	105.1 (8)
O2—C5—Si1	116.686 (18)	H10A-C10-H10C	104.8 (8)
C6—C5—Si1	130.12 (2)	H10B-C10-H10C	110.1 (8)
Si1—C1—C2—C3	177.42 (2)	C5—O2—C8—C7	-13.01 (4)
Sil—C5—C6—C7	-172.51 (2)	C5—C6—C7—C8	-10.06 (3)
O1—C1—C2—C3	-1.01 (4)	C6—C7—C8—O2	13.68 (4)
O2—C5—C6—C7	2.56 (4)	C8—O2—C5—Si1	-177.44 (2)
C1—Si1—C5—O2	-64.48 (2)	C8—O2—C5—C6	6.78 (4)
C1—Si1—C5—C6	110.44 (3)	C9—Si1—C1—O1	160.08 (2)
C1C4C3	4.15 (4)	C9—Si1—C1—C2	-18.30 (3)
C1—C2—C3—C4	3.38 (4)	C9—Si1—C5—O2	52.26 (3)
C2-C3-C4-O1	-4.46 (4)	C9—Si1—C5—C6	-132.81 (3)
C4—O1—C1—Si1	179.30 (2)	C10—Si1—C1—O1	36.82 (3)
C4—O1—C1—C2	-2.04 (4)	C10—Si1—C1—C2	-141.56 (3)
C5—Si1—C1—O1	-80.64 (2)	C10—Si1—C5—O2	177.38 (2)
C5—Si1—C1—C2	100.98 (3)	C10—Si1—C5—C6	-7.70 (3)

Z = 2F(000) = 284

 $D_{\rm x} = 1.227 {\rm Mg} {\rm m}^{-3}$

 $\theta = 2.5 - 36.3^{\circ}$

 $\mu = 0.15 \text{ mm}^{-1}$ T = 100 K

Plate, colourless

 $0.51 \times 0.19 \times 0.07 \text{ mm}$

Mo *K* α radiation, $\lambda = 0.71073$ Å

Cell parameters from 8775 reflections

(4,5-Dihydrofuran-2-yl)(methyl)diphenylsilane (2)

Crystal data

C₁₇H₁₈OSi $M_r = 266.40$ Triclinic, $P\overline{1}$ a = 8.7737 (4) Å b = 9.1715 (4) Å c = 9.8130 (4) Å $\alpha = 102.219$ (2)° $\beta = 90.613$ (2)° $\gamma = 110.280$ (2)° V = 720.85 (6) Å³

Data collection

Bruker D8 Venture	$T_{\rm min} = 0.713, \ T_{\rm max} = 0.747$
diffractometer	20409 measured reflections
Radiation source: microfocus sealed X-ray tube,	5826 independent reflections
INCOATEC microfocus sealed tube, Iys 3.0	4937 reflections with $I > 2\sigma(I)$
Multilayer optics monochromator	$R_{\rm int} = 0.030$
Detector resolution: 10.4167 pixels mm ⁻¹	$\theta_{\rm max} = 34.0^{\circ}, \ \theta_{\rm min} = 2.8^{\circ}$
φ and ω scans	$h = -11 \rightarrow 13$
Absorption correction: multi-scan	$k = -14 \rightarrow 14$
(SADABS; Krause et al., 2015)	$l = -15 \rightarrow 15$

Refinement

Refinement on F^2	0 restraints
Least-squares	Primary atom site location: iterative
matrix: full	Hydrogen site location: difference Fourier map
$R[F^2 > 2\sigma(F^2)] =$	H_atoms_treated_by_a_mixture_of_independent_and_constrained_refinem
0.040	$w = 1/[\sigma^2(F_o^2) + (0.0391P)^2 + 0.2951P]$
$wR(F^2) = 0.105$	where $P = (F_o^2 + 2F_c^2)/3$
S = 1.06	$(\Delta/\sigma)_{\rm max} < 0.001$
5826 reflections	$\Delta ho_{ m max} = 0.48 \ { m e} \ { m \AA}^{-3}$
244 parameters	$\Delta ho_{\min} = -0.27 \text{ e} \text{ Å}^{-3}$
Special details	

Geometry. All esds (except the esd in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell esds are taken into account individually in the estimation of esds in distances, angles and torsion angles; correlations between esds in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell esds is used for estimating esds involving l.s. planes.

	x	У	Ζ	$U_{ m iso}$ */ $U_{ m eq}$	
Si1	0.69854 (3)	0.37535 (3)	0.34297 (3)	0.01325 (7)	
01	0.92417 (10)	0.22237 (9)	0.28540 (9)	0.02194 (16)	
C1	0.86366 (11)	0.32897 (11)	0.24356 (10)	0.01447 (16)	
C2	0.93945 (12)	0.38813 (13)	0.13924 (11)	0.01886 (18)	
C3	1.07424 (14)	0.32450 (15)	0.10108 (13)	0.0250 (2)	
H3A	1.182 (2)	0.410(2)	0.1241 (18)	0.035 (4)*	
H3B	1.068 (2)	0.282 (2)	0.0052 (19)	0.037 (4)*	
C4	1.04574 (14)	0.20014 (14)	0.19082 (13)	0.0241 (2)	
H4A	1.003 (2)	0.091 (2)	0.1329 (18)	0.037 (4)*	
H4B	1.143 (2)	0.213 (2)	0.2498 (17)	0.034 (4)*	
C5	0.50711 (11)	0.19477 (11)	0.29840 (10)	0.01461 (16)	
C6	0.44747 (12)	0.11776 (12)	0.15886 (10)	0.01701 (17)	
H6	0.4976 (18)	0.1611 (17)	0.0857 (15)	0.021 (3)*	
C7	0.31274 (12)	-0.02389 (13)	0.12562 (11)	0.01983 (19)	
H7	0.276 (2)	-0.0716 (19)	0.0290 (17)	0.030 (4)*	
C8	0.23486 (13)	-0.09184 (13)	0.23187 (13)	0.0221 (2)	
H8	0.1407 (19)	-0.1954 (19)	0.2088 (16)	0.028 (4)*	
C9	0.28960 (13)	-0.01617 (13)	0.37054 (12)	0.0235 (2)	
H9	0.232 (2)	-0.063 (2)	0.4496 (17)	0.034 (4)*	
C10	0.42448 (12)	0.12571 (13)	0.40346 (11)	0.01958 (18)	
H10	0.4595 (19)	0.1741 (18)	0.5007 (16)	0.025 (4)*	
C11	0.68003 (11)	0.55198 (11)	0.28740 (10)	0.01557 (16)	
C12	0.54668 (13)	0.54371 (13)	0.20270 (11)	0.01901 (18)	
H12	0.4588 (18)	0.4466 (18)	0.1690 (15)	0.021 (3)*	
C13	0.53731 (15)	0.67991 (14)	0.16669 (12)	0.0236 (2)	
H13	0.447 (2)	0.6702 (19)	0.1106 (17)	0.029 (4)*	
C14	0.66219 (15)	0.82626 (14)	0.21337 (12)	0.0239 (2)	
H14	0.6560 (19)	0.9203 (19)	0.1908 (17)	0.029 (4)*	
C15	0.79733 (14)	0.83698 (13)	0.29579 (13)	0.0234 (2)	
C16	0.80543 (13)	0.70145 (12)	0.33290 (12)	0.02067 (19)	

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters (A^2)

H16	0.902 (2)	0.7112 (19)	0.3922 (17)	0.029 (4)*
C17	0.76169 (14)	0.42855 (14)	0.53383 (11)	0.02152 (19)
H17A	0.779 (2)	0.341 (2)	0.5607 (19)	0.042 (5)*
H17B	0.678 (2)	0.459 (2)	0.5845 (19)	0.041 (5)*
H15	0.886 (2)	0.9381 (19)	0.3294 (16)	0.028 (4)*
H17C	0.863 (2)	0.524 (2)	0.5574 (19)	0.045 (5)*
H2	0.9161 (19)	0.4673 (19)	0.1014 (16)	0.028 (4)*

Atomic displacement parameters $(Å^2)$

	U^{11}	U^{22}	U^{33}	U^{12}	U^{13}	U^{23}
Si1	0.01095 (11)	0.01317 (12)	0.01416 (12)	0.00328 (9)	0.00118 (8)	0.00181 (9)
01	0.0202 (3)	0.0199 (3)	0.0313 (4)	0.0113 (3)	0.0083 (3)	0.0103 (3)
C1	0.0112 (3)	0.0134 (4)	0.0177 (4)	0.0040 (3)	0.0002 (3)	0.0020 (3)
C2	0.0156 (4)	0.0227 (5)	0.0198 (4)	0.0084 (3)	0.0040 (3)	0.0054 (4)
C3	0.0176 (4)	0.0309 (6)	0.0272 (5)	0.0104 (4)	0.0078 (4)	0.0051 (4)
C4	0.0194 (4)	0.0225 (5)	0.0318 (6)	0.0116 (4)	0.0051 (4)	0.0019 (4)
C5	0.0114 (3)	0.0150 (4)	0.0170 (4)	0.0042 (3)	0.0020 (3)	0.0036 (3)
C6	0.0144 (4)	0.0176 (4)	0.0169 (4)	0.0044 (3)	0.0023 (3)	0.0015 (3)
C7	0.0150 (4)	0.0186 (4)	0.0217 (4)	0.0044 (3)	0.0004 (3)	-0.0014 (3)
C8	0.0158 (4)	0.0165 (4)	0.0307 (5)	0.0030 (3)	0.0023 (4)	0.0036 (4)
C9	0.0198 (4)	0.0210 (5)	0.0270 (5)	0.0019 (4)	0.0052 (4)	0.0088 (4)
C10	0.0171 (4)	0.0197 (4)	0.0192 (4)	0.0026 (3)	0.0025 (3)	0.0056 (4)
C11	0.0138 (4)	0.0149 (4)	0.0178 (4)	0.0055 (3)	0.0038 (3)	0.0024 (3)
C12	0.0176 (4)	0.0185 (4)	0.0214 (4)	0.0071 (3)	0.0017 (3)	0.0046 (3)
C13	0.0252 (5)	0.0249 (5)	0.0249 (5)	0.0127 (4)	0.0020 (4)	0.0084 (4)
C14	0.0303 (5)	0.0206 (5)	0.0265 (5)	0.0133 (4)	0.0083 (4)	0.0100 (4)
C15	0.0243 (5)	0.0159 (4)	0.0292 (5)	0.0058 (4)	0.0070 (4)	0.0055 (4)
C16	0.0169 (4)	0.0169 (4)	0.0265 (5)	0.0043 (3)	0.0019 (4)	0.0042 (4)
C17	0.0205 (4)	0.0237 (5)	0.0161 (4)	0.0040 (4)	0.0001 (3)	0.0025 (4)

Geometric parameters (Å, °)

Sil—Cl	1.8743 (10)	C8—H8	0.998 (16)
Si1—C5	1.8720 (9)	C8—C9	1.3854 (17)
Sil—Cl1	1.8715 (10)	С9—Н9	1.023 (16)
Sil—C17	1.8591 (11)	C9—C10	1.3944 (15)
01—C1	1.3897 (12)	C10—H10	0.960 (15)
O1—C4	1.4603 (13)	C11—C12	1.3988 (14)
C1—C2	1.3356 (14)	C11—C16	1.4050 (14)
C2—C3	1.5082 (15)	C12—H12	0.944 (15)
С2—Н2	0.961 (16)	C12—C13	1.3962 (15)
С3—НЗА	0.981 (17)	C13—H13	0.928 (16)
С3—Н3В	0.933 (18)	C13—C14	1.3861 (17)
C3—C4	1.5398 (18)	C14—H14	0.953 (16)
C4—H4A	0.982 (17)	C14—C15	1.3909 (17)
C4—H4B	0.987 (17)	C15—C16	1.3911 (15)
C5—C6	1.4023 (14)	C15—H15	0.969 (16)

C5-C10	1.4014 (13)	C16—H16	0.990 (16)
С6—Н6	0.934 (15)	C17—H17A	0.950 (18)
C6—C7	1.3926 (14)	C17—H17B	0.975 (19)
С7—Н7	0.956 (16)	C17—H17C	0.992 (19)
C7—C8	1.3919 (16)		
C5—Si1—C1	108.44 (4)	C7—C8—H8	120.4 (9)
C11—Si1—C1	105.50 (4)	C9—C8—C7	119.76 (10)
C11—Si1—C5	113.08 (4)	С9—С8—Н8	119.8 (9)
C17—Si1—C1	109.26 (5)	С8—С9—Н9	120.5 (9)
C17—Si1—C5	110.48 (5)	C8—C9—C10	120.10 (10)
C17—Si1—C11	109.89 (5)	С10—С9—Н9	119.4 (9)
C1—O1—C4	107.48 (8)	C5-C10-H10	121.0 (9)
O1—C1—Si1	117.13 (7)	C9—C10—C5	121.24 (10)
C2—C1—Si1	129.71 (8)	C9—C10—H10	117.7 (9)
C2-C1-O1	113.10 (9)	C12—C11—Si1	123.40(7)
C1—C2—C3	110.25 (9)	C12—C11—C16	117.71 (9)
C1—C2—H2	123.6 (9)	C16—C11—Si1	118.89 (8)
С3—С2—Н2	126.0 (9)	C11—C12—H12	121.5 (9)
С2—С3—Н3А	111.2 (10)	C13—C12—C11	121.09 (10)
С2—С3—Н3В	112.3 (11)	C13—C12—H12	117.4 (9)
C2—C3—C4	101.51 (9)	C12—C13—H13	118.8 (10)
НЗА—СЗ—НЗВ	105.5 (14)	C14—C13—C12	120.16 (10)
C4—C3—H3A	112.9 (10)	C14—C13—H13	121.0 (10)
C4—C3—H3B	113.7 (11)	C13—C14—H14	120.8 (10)
O1—C4—C3	106.70 (8)	C13—C14—C15	119.80 (10)
O1—C4—H4A	108.8 (10)	C15—C14—H14	119.4 (10)
O1—C4—H4B	107.0 (10)	C14—C15—C16	119.92 (10)
C3—C4—H4A	111.5 (10)	C14—C15—H15	121.1 (9)
C3—C4—H4B	114.2 (10)	C16—C15—H15	119.0 (9)
H4A—C4—H4B	108.4 (14)	C11—C16—H16	119.7 (9)
C6—C5—Si1	121.29 (7)	C15—C16—C11	121.32 (10)
C10-C5-Si1	120.94 (7)	C15—C16—H16	118.9 (9)
C10—C5—C6	117.64 (9)	Si1—C17—H17A	109.9 (11)
С5—С6—Н6	120.3 (9)	Si1—C17—H17B	108.7 (11)
C7—C6—C5	121.26 (9)	Si1—C17—H17C	110.5 (11)
С7—С6—Н6	118.4 (9)	H17A—C17—H17B	112.2 (15)
С6—С7—Н7	118.2 (10)	H17A—C17—H17C	109.4 (15)
C8—C7—C6	119.98 (10)	H17B—C17—H17C	106.1 (15)
С8—С7—Н7	121.8 (10)		
Si1—C1—C2—C3	175.12 (8)	C6—C7—C8—C9	1.46 (16)
Sil—C5—C6—C7	174.69 (8)	C7—C8—C9—C10	-1.42 (17)
Si1—C5—C10—C9	-174.66 (9)	C8—C9—C10—C5	0.07 (17)
Si1-C11-C12-C13	178.63 (8)	C10—C5—C6—C7	-1.15 (15)
Si1-C11-C16-C15	-179.42 (8)	C11—Si1—C1—O1	167.77 (7)
O1—C1—C2—C3	-2.00 (12)	C11—Si1—C1—C2	-9.26 (11)
C1—Si1—C5—C6	-51.23 (9)	C11—Si1—C5—C6	65.41 (9)

C1—Si1—C5—C10	124.48 (8)	C11—Si1—C5—C10	-118.88 (9)
C1—Si1—C11—C12	109.11 (9)	C11—C12—C13—C14	0.82 (17)
C1—Si1—C11—C16	-71.17 (9)	C12—C11—C16—C15	0.31 (15)
C1—O1—C4—C3	8.95 (11)	C12—C13—C14—C15	0.27 (17)
C1—C2—C3—C4	7.17 (12)	C13—C14—C15—C16	-1.03 (17)
C2-C3-C4-O1	-9.52 (11)	C14-C15-C16-C11	0.74 (17)
C4—O1—C1—Si1	177.92 (7)	C16—C11—C12—C13	-1.09 (15)
C4—O1—C1—C2	-4.57 (12)	C17—Si1—C1—O1	49.68 (8)
C5—Si1—C1—O1	-70.80 (8)	C17—Si1—C1—C2	-127.35 (10)
C5—Si1—C1—C2	112.17 (10)	C17—Si1—C5—C6	-170.95 (8)
C5—Si1—C11—C12	-9.26 (10)	C17—Si1—C5—C10	4.76 (10)
C5—Si1—C11—C16	170.46 (8)	C17—Si1—C11—C12	-133.23 (9)
C5—C6—C7—C8	-0.15 (16)	C17—Si1—C11—C16	46.49 (9)
C6—C5—C10—C9	1.20 (15)		

Hydrogen-bond geometry (Å, °)

<i>D</i> —H··· <i>A</i>	D—H	H…A	D····A	D—H···A
C15—H15…O1 ⁱ	0.969 (16)	2.640 (16)	3.3422 (13)	129.6 (12)
C17—H17 <i>C</i> ···O1 ⁱⁱ	0.992 (19)	2.584 (19)	3.5168 (14)	156.5 (15)

Symmetry codes: (i) *x*, *y*+1, *z*; (ii) -*x*+2, -*y*+1, -*z*+1.

Selected geometric parameters for compound 1 (Å , °)

Si1—C1	1.8742 (3)	C1—Si1—C5	108.189 (12)	
Sil—C5	1.8693 (3)	C1—Si1—C9	106.801 (14)	
Sil—C9	1.8631 (3)	C1—Si1—C10	109.191 (13)	
Sil—C10	1.8579 (3)	C5—Si1—C9	110.770 (15)	
		C5—Si1—C10	108.128 (13)	
C1—C2	1.3370 (4)	C9—Si1—C10	113.628 (16)	
C3—C4	1.5331 (5)			
C5—C6	1.3409 (4)			
С7—С8	1.5298 (5)			